

MOLYBDENUM SPUTTERING TARGET, METHOD FOR
PRODUCING SAME, AND METHOD FOR PRODUCING
SPUTTERING FILM USING MOLYBDENUM SPUTTERING
TARGET

5

ABSTRACT

A molybdenum sputtering target includes molybdenum. The
molybdenum sputtering target contains crystal grains having an average
crystal grain size of less than 10 μm and has a relative density of 99.6%
or more and an oxygen content of 100 ppm by mass or less.

10

[Fig. 3]